

UNITED STATES DEPARTMENT OF COMMERCE

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APPLICATION NO.	FILING DATE	FIRST NAMED INVENTOR		A	TTORNEY DOCKET NO.
09/672,776	09/29/00	ONO		F	Q61045
Γ	- TMCC / OF CC			EXAMINER	
IM22/0522 ' SUGHRUE MION ZINN MACPEAK & SEAS PLLC 2100 PENNSYLVANIA AVENUE NW			BROWN,C		
				ART UNIT	PAPER NUMBER
WASHINGTON	DC 20037-32	213		1765	7
				DATE MAILED:	05/22/01

Please find below and/or attached an Office communication concerning this application or proceeding.

Commissioner of Patents and Trademarks

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Office Action Summary

Application No. 09/672,776

Applicant(s)

Ono

Examiner

Charlotte A. Brown

Art Unit **1765**



De tod for Dools			
Period for Reply			
A SHORTENED STATUTORY PERIOD FOR REPLY IS SET TO EXPIRE3 MONTH(S) FROM THE MAILING DATE OF THIS COMMUNICATION.			
 Extensions of time may be available under the provisions of 37 CFR 1.136 (a). In no event, however, may a reply be timely after SIX (6) MONTHS from the mailing date of this communication. If the period for reply specified above is less than thirty (30) days, a reply within the statutory minimum of thirty (30) days we be considered timely. If NO period for reply is specified above, the maximum statutory period will apply and will expire SIX (6) MONTHS from the communication. Failure to reply within the set or extended period for reply will, by statute, cause the application to become ABANDONED (3) 	vill mailing date of this 5 U.S.C. § 133).		
 Any reply received by the Office later than three months after the mailing date of this communication, even if timely filed, m earned patent term adjustment. See 37 CFR 1.704(b). 	ay reduce any		
Status			
1) Responsive to communication(s) filed on Mar 16, 2001	·		
2a) ☐ This action is FINAL . 2b) ☒ This action is non-final.			
3) Since this application is in condition for allowance except for formal matters, prosecution as to the microsed in accordance with the practice under <i>Ex parte Quayle</i> , 1935 C.D. 11; 453 O.G. 213.	erits is		
Disposition of Claims			
4) Claim(s) 6-9 is/are pending in the ap	plication.		
4a) Of the above, claim(s) is/are withdrawn from	consideration.		
5) Claim(s) is/are allowed.			
6) 💢 Claim(s) <u>6-9</u> is/are rejected.			
7) Claim(s) is/are objected to.			
8) Claims are subject to restriction and/or election	on requirement.		
Application Papers			
9) The specification is objected to by the Examiner.			
10) The drawing(s) filed on is/are objected to by the Examiner.			
11) The proposed drawing correction filed on is: a) approved b) disapproved.			
12) The oath or declaration is objected to by the Examiner.			
Priority under 35 U.S.C. § 119 13) Acknowledgement is made of a claim for foreign priority under 35 U.S.C. § 119(a)-(d).			
a) ☐ All b) ☐ Some* c) ☐ None of:			
1. Certified copies of the priority documents have been received.			
2. Certified copies of the priority documents have been received in Application No.	•		
3. Copies of the certified copies of the priority documents have been received in this National Stag application from the International Bureau (PCT Rule 17.2(a)).	ge		
*See the attached detailed Office action for a list of the certified copies not received. 14) Acknowledgement is made of a claim for domestic priority under 35 U.S.C. § 119(e).			
Attachment(s) 15) Notice of References Cited (PTO-892) 18 Interview Summary (PTO-413) Paper No(s)			
15) Notice of References Cited (PTO-892) 18) Interview Summary (PTO-413) Paper No(s) 16) Notice of Draftsperson's Patent Drawing Review (PTO-948) 19) Notice of Informal Patent Application (PTO-152)			
17) Information Disclosure Statement(s) (PTO-1449) Paper No(s) 20) Other:			

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DETAILED ACTION

- 1. Applicant's arguments with respect to claims 6-9 have been considered but are moot in view of the new ground(s) of rejection.
- 2. The following is a quotation of 35 U.S.C. 103(a) which forms the basis for all obviousness rejections set forth in this Office action:
 - (a) A patent may not be obtained though the invention is not identically disclosed or described as set forth in section 102 of this title, if the differences between the subject matter sought to be patented and the prior art are such that the subject matter as a whole would have been obvious at the time the invention was made to a person having ordinary skill in the art to which said subject matter pertains. Patentability shall not be negatived by the manner in which the invention was made.
- 3. Claims 6-9 are rejected under 35 U.S.C. 103(a) as being unpatentable over Kasai et al. (US 6,007,592) in view of Streinz et al. (US 6,015,506).

Kasai discloses a polishing composition for an aluminum disk that includes water, an alumina abrasive agent and a polishing accelerator. The polishing accelerator is preferably basic aluminum nitrate. The abrasive agent is alumina. The alumina particles have a mean particle size of 0.1 to 0.4 um (Column 3, lines 56-62). The alumina has an alumina crystalline structure with an alpha-phase content of 80% to 95% (Column 4, lines 4-16). This reads on the applicant's limitation that the alumina particles have an alpha conversion ratio of from 65% to 90%.

Unlike the claimed invention, Kasai does not teach a method in which the alumina particles have a specific surface area of from 30 to $80 \text{m}^2/\text{g}$.

Streinz discloses a method for polishing rigid disks. The rigid disk can be an aluminum disk. The abrasive used in the chemical mechanical polishing slurry is fumed alumina. The surface

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area of the fumed alumina is about $40 \text{ m}^2/\text{g}$ to about $200 \text{ m}^2/\text{g}$ (Column 3, lines 45-64). The abrasive is incorporated into the aqueous medium of the polishing slurry. The slurry is diluted with deionized water or any other acceptable diluent (Column 4, lines 40-50).

It is the Examiner's position that a person having ordinary skill in the art would have found it obvious to modify Kasai with the method of using alumina particles with a specific surface area of from 30 to 80 m²/g as taught by Streinz. The method of using alumina particles with a specific surface area in the polishing composition would have been anticipated in order to reduce the generation of scratches on the polishing surface.

4. Any inquiry concerning this communication from the Examiner should be directed to Charlotte A. Brown whose telephone number is (703) 305-0727.

CAB

May 17, 2001

ROBERT KUNEMUND PRIMARY EXAMINER